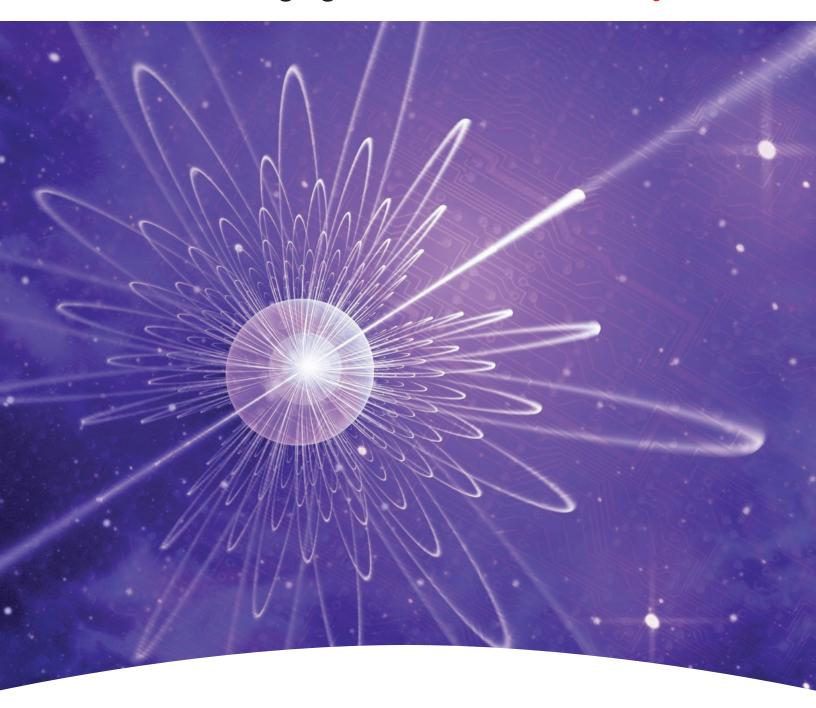
Advanced Packaging

Honeywell



Honeywell RadLo™ Low Alpha Packaging Materials

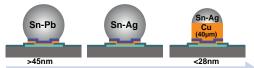
Honeywell RadLo™ Low Alpha Materials for Advanced Packaging Solutions

Enabling High-Performance Devices

Alpha emissions from packaging materials can cause soft errors in vulnerable devices. Honeywell has developed a wide range of low alpha packaging materials to meet this challenge.



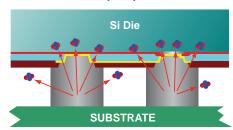
Impact of Alpha Emissions on Device Performance



Evolution of Solder Bumping Technology

Device miniaturization puts packaging materials, such as wafer bumps and Cu pillar solder caps, in proximity to critical device layers. Flip-chip devices and 3-D wafer-level chips are particularly vulnerable to alpha emissions from these packaging materials.

Wafer Bump Alpha Issues



Alpha Particles from Solder

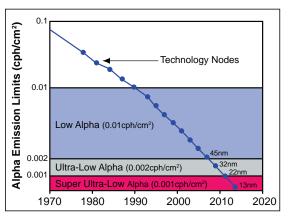
Industry Needs

To Reduce Soft Errors in Devices, Packaging Materials Must:

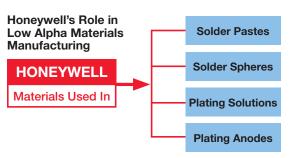
- Meet critical alpha emission specifications
- Exhibit stable alpha emission levels over time
- Be customizable and offer ease of integration

RadLo Materials:

- Reduction in alpha-emitting contaminants enables materials to meet emission specifications
- Metrology processes help ensure that alpha emissions from materials do not increase over time
- Available in various form factors and alloys



Device Miniaturization Drives Need for Lower Alpha Emissions



Product Types:

- Lead-based and lead-free solder feedstock
- Low alpha tin-based anodes for plating systems
- SnO and Sn-MSA for plating solution material

Custom Development

Honeywell's development team will partner with customers to create custom alloys.



Honeywell RadLo™ Materials
Above: Solder Feedstock
and Plating Anodes.
Right: Plating Solution
Materials



RadLo Products are Available in 3 Alpha Grades:

- Low alpha grade (<0.01/counts/hr/cm²)
- Ultra-low alpha grade (<0.002 counts/hr/cm²)
- Super ultra-low alpha grade (<0.001counts/hr/cm²)

Our products are manufactured to meet 99.99% (4N) or higher purity.

Technology Leadership

- Advanced metrology processes based on industry-wide alpha measurement standards
- Proprietary refining techniques involving selective removal of alpha-emitting isotopes
- State-of-the-art research in alpha emitter properties and transport mechanisms supports development of next-generation products

Proven Solutions

Honeywell RadLo materials offer proven reliability in various applications. Our experience and expertise in low alpha manufacturing spans two decades.

Technical Support

We offer comprehensive technical guidance to support our customers' needs.

Honeywell Advantages

Products &

Features

HONEYWELL RESOURCES:

- Application Support and Qualification Information
- Detailed Specifications
- Ordering Information

For Additional Information, Visit www.honeywell-lowalpha.com

Choose Honeywell RadLo Low Alpha Packaging Solutions



Honeywell RadLo[™] **Low Alpha Materials** for Advanced Packaging **Solutions**



Honeywell Electronic Materials

USA: 1-509-252-2102 China: 86-21-28942481 **Germany:** 49-5137-999-9199 **Japan:** 81-3-6730-7092 Korea: 82-2-3483-5076 **Singapore:** 65-6580-3593 Taiwan: 886-3-6580300 ext.312

www.honeywell-lowalpha.com

Although all statements and information contained herein are believed to be accurate and reliable, they are presented without guarantee or warranty of any kind, express or implied. Information provided herein does not relieve the user from the responsibility of carrying out its own tests and experiments, and the user assumes all risks and liability for use of the information and results obtained. Statements or suggestions concerning the use of materials and processes are made without representation or warranty that any such use is free of patent infringement and are not recommendations to infringe any patent. The user should not assume that all trovictly data and safety measures are indicated. user should not assume that all toxicity data and safety measures are indicated herein or that other measures may not be required. PB1630812Rev2

©2012 Honeywell International Inc.

Although all statements and information contained herein are believed to be

